Memory is Key to Intelligence

From near-memory computing to in-memory computing

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Human Learning is Based on Experience



Machine Learning is Based on Massive Amount of Data

A Lot of Data...



100

Training a single AI model consumes a lot of energy

"Training a single AI model can emit as much as 300X a roundtrip flight from NYC to SFO"

MIT TECHNOLOGY REVIEW, JUNE 2019

Common carbon footprint benchmarks in lbs of CO₂ equivalent



Source: MIT Technology Review Source: Strubell et al. Transformer (213M parameters) w/ neural architecture search



Because Moving Bits Over a DRAM Bus Consumes a Lot

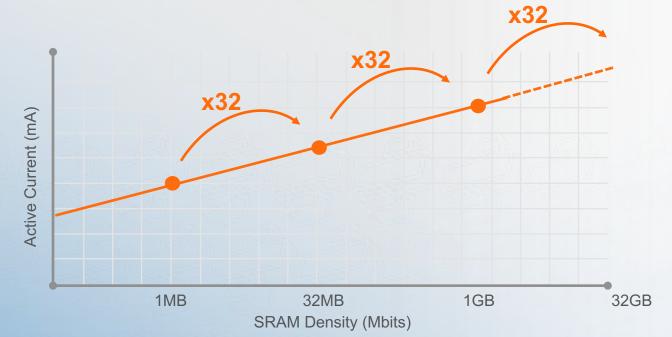
Reads from DDR4 DIMMs: 320 pJ/Byte Reads from HBM DRAM: 64 pJ/Byte

In AI, the data movement off-chip causes a lot of penalty in energy and latency. That is a bottleneck.



And Using Embedded SRAM Has a Leakage Problem

on-chip SRAM has shorter wires to processor but has a fundamental leakage problem

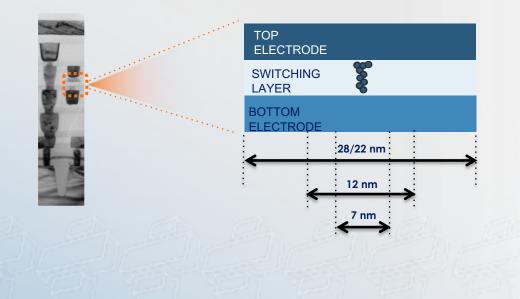


Reads from SRAM at 6 pJ/bit for 8 Mbit but getting worse for higher densities



One Alternative is to Use Embedded ReRAM

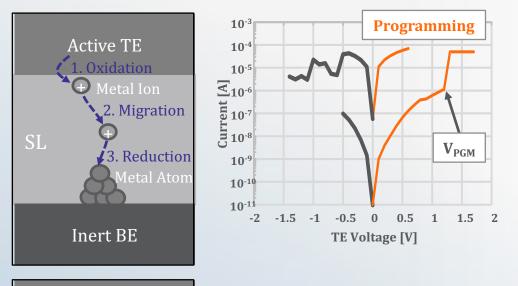
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- Non-volatile memory cell **no leakage**
- Monolithic CMOS integration: located between any metal layers
- **3** Scalable: **5nm metal filament**
- 4 Low energy: 15ns reads <0.5pJ/bit
 - 1M write cycles **10 years retention**

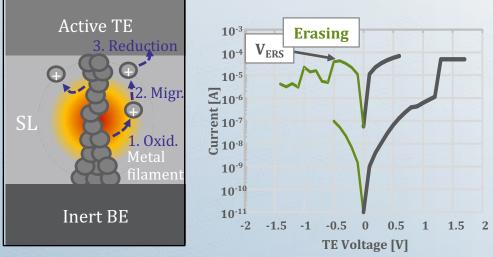


ReRAM Fundamentals



Programming: Positive Voltage on Top Electrode

→ ON state is reached when a complete filament is created between both electrodes



Erasing: Positive Voltage on Bottom Electrode

→ OFF state is reached when the conductive path is broken

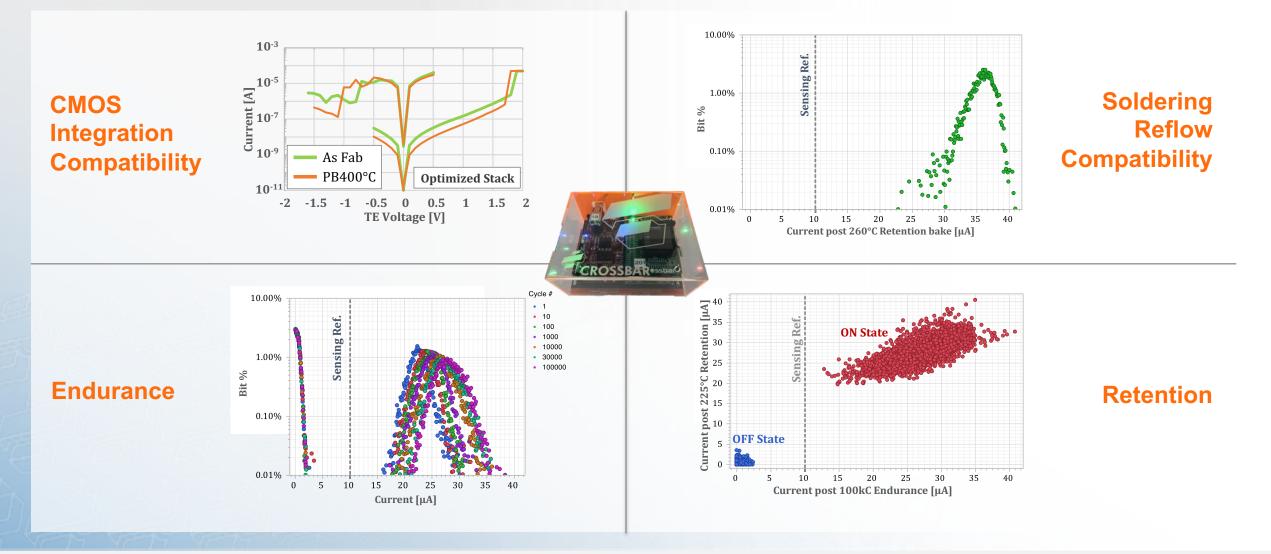


How Does ReRAM Compare With Other eNVM

	Target Commercial	Target Commercial	Commercial
	Crossbar ReRAM	Embedded MRAM	Embedded Flash
Scalability	28 / 22 nm	22 nm	40 nm
Cost	3 layers	20+ layers	dedicated CMOS
	0 new elements	9+ new elements	front-end
	2 additional masks	5 additional masks	12 additional masks
	0.03 um ² cell size	0.05 um ² cell size	0.07 um ² cell size
Energy	0.4 uA/MHz/bit read current	2 uA/MHz/bit read current	1.6 uA/MHz/bit read current
	4 uA standby current	200 uA standby current	150 uA standby current
Other Characteristics	15ns read latency 1M write cycles 10 years retention Magnetic immunity	15ns read latency 1M write cycles 10 years retention No magnetic immunity	25ns read latency 100K write cycles 10 years retention Magnetic immunity



Ready to engage. Here's Our Latest Results





Today: Near-Memory Computing



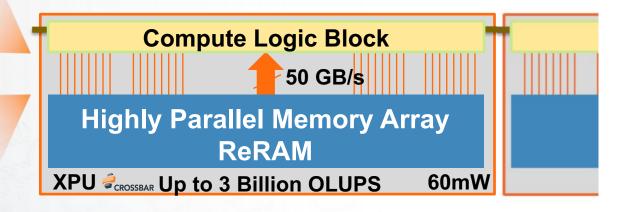
Today: Near-Memory Computing

Compute Logic Block

- Host interface @ 66MHz
- 1000s of computation engines
- Up to 3 Billion Object LookUp Per Sec (OLUPS)
- Decision module
- Wide internal memory bus 50GB/s

Memory Array

- Non-volatile ReRAM
- 50GB/s memory bus
- 8K bit lines



Targeted for massive search/lookups, kNN, RBF, CBIR, Softmax

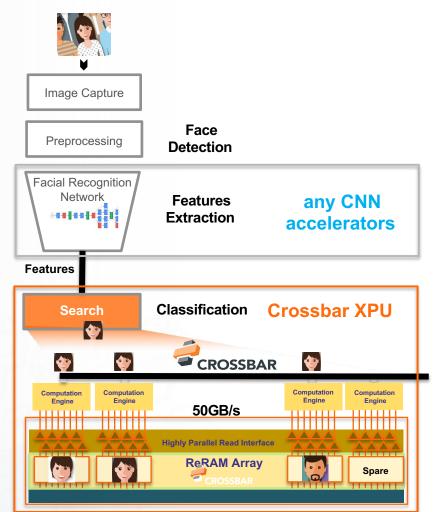


Example: Face Recognition

Classification is currently performed on host CPU

→ Use Crossbar XPU to compare feature representations against many

Deterministic Performance Persistent Memory Configurable Scalable Low Power



Enabling Learning at the Edge



Ready to Engage

ReThink Classification with Crossbar ReRAM



Visit Booth #15



What's Next: Persistent Memory



High-density Persistent Memory for Data Centers



Read performance - 25.6GB/s - 64 IOs – 250ns random reads **Low power -** persistent memory and <1W active reads **Endurance|Retention** – 10M | 6 months

8GB ReRAM chip

DRAM read performance - 3.2GB/s interface - 8 IOs
Non-volatile - No current drawn during inactivity
Low energy - 68mA active read current - 3.6 pJ/bit
Lower cost than DRAM 1~2\$/GB



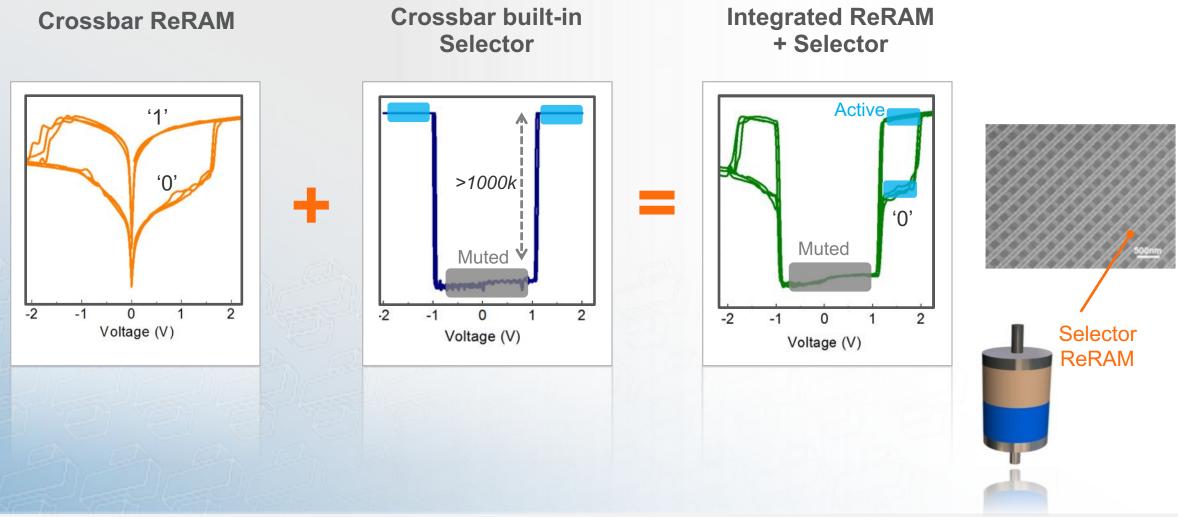
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REPAN

ROBAM

NVDIMM Controlle

How is it Possible: Crossbar Selector



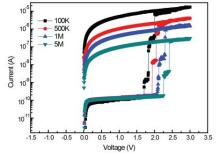


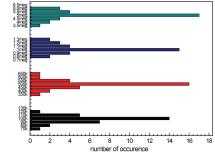
Future is In-Memory Computing

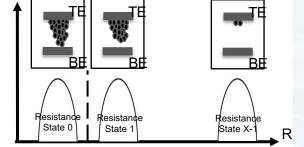


In-Memory Computing

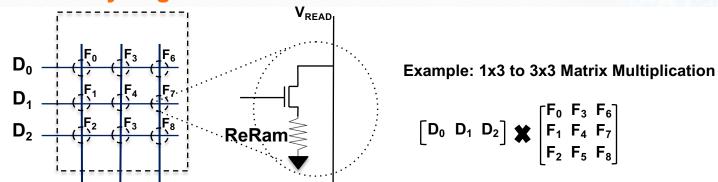
Device & Circuits







In-Memory Logic



Briving



Crossbar: From Near-Memory to In-Memory Computing

- Based in Santa Clara, CA, U.S.A.
- \$120M in raised capital to date
- Leader in Resistive RAM technology
- New class of non volatile memory: Metal Filament Resistor
- Back-end of line Non Volatile Memory: 2x nm, 1x nm
- Patented Technology: 310 filed / 160 issued
- Applications in Persistent Memory, AI, FPGAs, eNVM
- Efficient search and computing with Highly Parallel Memory







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